**MATERIALS RESEARCH SOCIETY** 

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Contact materials for nanoelectronics

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The Materials Theory Award recognizes exceptional advances made by materials theory to the fundamental understanding of the structure and behavior of materials. The Award is intended to honor both those who have pioneered the development of a new theoretical approach and those who have used existing approaches to provide significant new

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- · Nominees need not be members of the Materials Research Society.
- · Current members of the Materials Theory Award Subcommittee and MRS Board members are not eligible.
- · The Award is presented at the MRS Fall Meeting.
- The Award will not be bestowed in absentia except in extraordinary circumstances.

#### **DEADLINE FOR NOMINATIONS—April 1, 2011**

For more information on the Materials Theory Award, including administration and nomination requirements, visit www.mrs.org/mta.

MRS acknowledges the generosity of Professors Gwo-Ching Wang and Toh-Ming Lu for endowing this award.

For additional information on any of the MRS Awards noted above. visit www.mrs.org/awards.





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#### ON THE COVER

Contact materials for nanoelectronics. This issue of MRS Bulletin reviews current

development of contact materials for electronic and nanoelectronic devices. On the cover is a top-down view of transistors and associated electrical contacts to the transistor gate electrodes and junction silicides. The transistor channel length is nearly 90 nm. Transistor scaling to the nanoscale and adoption of new contact and channel materials has created many challenges and opportunities for materials scientists. Image courtesy of Texas Instruments, Inc. See the technical theme that begins on p. 90.



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The Society's interdisciplinary approach differs from that of single-discipline professional societies because it promotes information exchange across the many technical fields touching materials development. MRS sponsors two major international annual meetings encompassing approximately 70 topical symposia, and also sponsors numerous single-topic scientific meetings. The Society recognizes professional and technical excellence and fosters technical interaction in local geographic regions through Sections and University Chapters.

MRS participates in the international arena of materials research through the International Union of Materials Research Societies (IUMRS). MRS is a member of ASTRA and is an affiliate of the American Institute of Physics.

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